

Chimia News

Editorial Board

Dear CHIMIA readers,

Together with my colleagues of the Editorial Board I wish you all the best and much success and happiness in 2012.

The current members of the Editorial Board will remain at the helm for 2012. In 2013/14 the positions of the assistant editor and the editor-in-chief will both become available. Applications of candidates from the industrial and academic communities are welcome.

The planned content in 2012 is again composed of topical issues and contributions from the Swiss Chemical Society and its Divisions. As in the past, this year's issues will be organized and supervised by recognized specialists, and it is with great pleasure that I thank them for their demanding voluntary work that is so important for us. We all hope that you will enjoy the CHIMIA issues of 2012.

Roland W. Kunz, Chairman

Contents 2012

- 1/2 30 Years STM (Karl-Heinz Ernst, EMPA Dübendorf)
- 3 New Professors (Jérôme Lacour, University of Geneva)
- 4 Laureates & Awards (Sandrine Gerber, EPF Lausanne)
- 5 Geneva Pharma (Muriel Cuendet and Eric Allemann, University of Geneva)
- 6 Radical Chemistry (Philippe Renaud, University of Bern)
- 7/8 Fall Meeting (Hans Peter Lüthi, ETH Zürich)
- 9 Heterogeneous Catalysis (Davide Ferri, EMPA, Jeroen van Bokhoven, ETH Zurich, and Liubow Kiwi-Minsker, EPF Lausanne)
- 10 NMR (Mathias Ernst and Roland Riek, ETH Zurich)
- 11 Outreach Initiatives (Farnaz Moser, EPF Lausanne, and Reto Naef, Novartis Basel)
- 12 Chemistry in India (Peter Maienfisch, Syngenta Crop Protection Münchwilen AG)

Indexing

CHIMIA is now indexed in *MEDLINE* on a regular basis. All issues back to 2009 were also indexed. As in the past, CHIMIA is indexed by *Chemical Abstracts Services*, *Science Citation Index* and *Scopus*.

On-Line Availability

CHIMIA has been electronically available at <http://www.ingentaconnect.com/content/scs/chimia> since the beginning of 2005. SCS members have free access to this on-line version as part of their membership. To register for electronic access as a personal member or subscriber, please follow the steps described in http://www.chimia.ch/serv/dnld/guidelines_personal.pdf

Subscription and membership entitles to access all electronic articles from 1990 onwards, as well as any additional back volume when it becomes available.

Institutional subscriptions are per site, where a site is defined as "all terminals and workstations owned and controlled by the subscriber in a single, geographically contiguous office building or complex or campus location within the same city or agglomeration". International companies with distributed R&D sites are treated as consortia and qualify for a discount of 50% for additional sites with electronic access. For companies that are members of the Swiss Chemical Society, the first site is free (included in the membership).

Open Access Publishing

CHIMIA allows authors to post their own published articles in the Internet under some obligations. Posting is only allowed on the author's personal website and/or in non-profit and non-commercial repositories of the author's institution and/or funding-body, the public availability of posted full articles must be delayed until **12 months after print publication** in the journal and copyright and source must be properly acknowledged. There is no embargo for posting bibliographic meta data including abstracts. The publisher's version of PDF must be used. These PDF documents are available at Ingenta – for members of the Swiss Chemical Society free of charge.

Immediate release to OAP is available upon payment of the full production costs of the article.

Advertisement and Printing

CHIMIA extended its collaboration with *FO-Zürisee* (www.fo-zuerisee.ch, formerly Zürichsee Druckereien AG) for another two years, and *SIGWERB GmbH* in Zug (www.sigwerb.com) fortunately remains our advertisement partner.

Plagiarism

Late in 2011 we were informed of a possible case of plagiarism in a past issue of CHIMIA. Plagiarism is not acceptable, and CHIMIA will take appropriate action if we become aware of such dishonest conduct and theft of intellectual property. The authors will remain responsible for ensuring that any citations are clearly marked and correctly cited.